

Docket No.: SON-3162

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Toshihiko Shirasagi, et al

Application No.: 10/579,211 Confirmation No.: 6592

Filed: May 12, 2006 Art Unit: 1756

For: MANUFACTURING METHOD OF MASTER Examiner: Not Yet Assigned

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## SECOND INFORMATION DISCLOSURE STATEMENT (IDS)

MS AMENDMENT Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

FEB 1 5 2007

In accordance with the requirements of 37 CFR §§ 1.56 and MPEP 609, the Applicant, through its representatives and attorneys, hereby provides for the attention of the examiner copies of the three non-patent documents cited at page 3 of the specification. This submission is timely in that it is made prior to a first action on the merits of the application. The relevance of these documents is noted at pages 1 to 5 of the specification as filed. Please take these documents into account along with the information at pages 1 to 5 of the specification as filed and make such consideration of record.

Applicant believes no fee is due with this response. However, if a fee is due, please charge our Deposit Account No. 18-0013, under Order No. SON-3162 from which the undersigned is authorized to draw.

Dated: February 15, 2007

Respectfully submitted,

Ronald P. Kananen

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## INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use as many sheets as necessary)

1 of Sheet 1

| Complete if Known      |                          |  |  |  |
|------------------------|--------------------------|--|--|--|
| Application Number     | 10/579,211 - Conf.# 6592 |  |  |  |
| Filing Date            | May 12, 2006             |  |  |  |
| First Named Inventor   | Toshihiko Shirasagi      |  |  |  |
| Art Unit               | 1756                     |  |  |  |
| Examiner Name          | Not Yet Assigned         |  |  |  |
| Attorney Docket Number | SON-3162                 |  |  |  |

| U.S. PATENT DOCUMENTS |              |   |                                |  |   |
|-----------------------|--------------|---|--------------------------------|--|---|
| Examiner<br>Initials* | Cite<br>No.1 | Document Number Number-Kind Code <sup>2</sup> ( <i>if known</i> ) | Publication Date<br>MM-DD-YYYY | Name of Patentee or<br>Applicant of Cited Document | Pages, Columns, Lines, Where<br>Relevant Passages or Relevant<br>Figures Appear |
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|                       |              | FOREIC   | ON PATENT                         | DOCUMENTS  |   |                |
|-----------------------|--------------|--|-----------------------------------|--|---|----------------|
| Examiner<br>Initials* | Cite<br>No.1 | Foreign Patent Document  Country Code <sup>3</sup> -Number <sup>4</sup> -Kind Code <sup>5</sup> (if known) | Publication<br>Date<br>MM-DD-YYYY | Name of Patentee or<br>Applicant of Cited Document | Pages, Columns, Lines,<br>Where Relevant Passages<br>or Relevant Figures Appear | T <sup>6</sup> |
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| NON PATENT LITERATURE DOCUMENTS   |    |  |    |  |
|---|----|--|----|--|
| magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), pu |    | Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.  | T² |  |
|   | CA | N. Koshida et al., "50-nm Metal Line Fabrication by Focused Ion Beam and Oxide Resists," Japanese Journal of Applied Physics, Vol. 30, No. 11B, November 1991, pp. 3246-3249   |    |  |
|   | СВ | S. M. Gorwadkar et al., "SiO <sub>2</sub> / <sub>c</sub> -Si Bilayer Electron-Beam Resist Process for Nano-Fabrication," Japanese Journal of Applied Physics, Vol. 35 (1996), Part 1, No. 12B, pp. 6673-6678, December 1996  |    |  |
|   | СС | S. A. Kostyukevych, "Investigations and modeling of physical processes in inorganic resists for the use in UV and laser lithography," Institute of Physics of Semiconductors, National Academy of Sciences Prospect Nauki 45, Kiev, 252028, UKRAINE, part of the SPIE Conference on Inorganic Optical Materials, California, SPIE Vol. 3424, July 1998 |    |  |

<sup>\*</sup>EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

| Examiner Date Signature Considered |           | The state of the s |
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| Signature Considered Considered    | Examiner  | Date   |
|                                    | Signature | Considered   |

<sup>&#</sup>x27;Applicant's unique citation designation number (optional). <sup>2</sup>Applicant is to place a check mark here if English language Translation is attached.